Ref #	Hits	Search Query	DBs	Default Operator		Time Stamp
S1	673	plasma adj surface adj treatment	US-PGPUB; USPAT; EPO; JPO; IBM_TDB	OR	ON	2005/11/01 11:03
S2	453	S1 and substrate	US-PGPUB; USPAT; EPO; JPO; IBM_TDB	OR	ON	2005/11/01 11:03
S3	79	S2 and (electric adj field)	US-PGPUB; USPAT; EPO; JPO; IBM_TDB	OR 	ON	2005/11/01 11:03
S4	1	S3 and (pulse adj modulation)	US-PGPUB; USPAT; EPO; JPO; IBM_TDB	OR	ON	2005/11/09 14:58
S5	13220	plasma and (surface adj treatment)	US-PGPUB; USPAT; EPO; JPO; IBM_TDB	OR	, ON	2005/11/01 11:03
S6 .	8914	S5 and substrate	US-PGPUB; USPAT; EPO; JPO; IBM_TDB	OR	ON	2005/11/01 11:03
S7	1646	S6 and (electric adj field)	US-PGPUB; USPAT; EPO; JPO; IBM_TDB	OR	ON .	2005/11/09 10:55
S8	8	S7 and (pulse adj modulation)	US-PGPUB; USPAT; EPO; JPO; IBM_TDB	OR	ON	2005/11/09 10:56
S9	1	S8 and aperture	US-PGPUB; USPAT; EPO; JPO; IBM_TDB	OR	ON	2005/11/09 10:57
S10	4	S8 and (hole or stop)	US-PGPUB; USPAT; EPO; JPO; IBM_TDB	OR	ON	2005/11/02 10:38
S11	70	Fukuda-Seiichi.IN.	US-PGPUB; USPAT; EPO; JPO; IBM_TDB	OR	ON	2005/11/01 11:18
S12	51	Samukawa-Seiji.IN.	US-PGPUB; USPAT; EPO; JPO; IBM_TDB	OR	ON	2005/11/01 11:18

Cin	4	C11 and C12	LIC DCDUB			2005/11/01 11:10
S13	1	S11 and S12	US-PGPUB; USPAT; EPO; JPO;	UK	ON	2005/11/01 11:19
		l I	IBM_TDB			
S14	13255	plasma and (surface adj treatment)	US-PGPUB; USPAT; EPO; JPO; IBM_TDB	OR	ON	2005/11/09 10:55
S15	8943	S14 and substrate	US-PGPUB; USPAT; EPO; JPO; IBM_TDB	OR	ON	2005/11/09 10:55
S16	1653	S15 and (electric adj field)	US-PGPUB; USPAT; EPO; JPO; IBM_TDB	OR	ON	2005/11/09 10:58
S17	52	S16 and (nitrogen adj plasma)	US-PGPUB; USPAT; EPO; JPO; IBM_TDB	OR	ON	2005/11/09 10:58
S18	1	S17 and (pulse adj modulation)	US-PGPUB; USPAT; EPO; JPO; IBM_TDB	OR	ON	2005/11/09 10:58
S19	1	S18 and aperture	US-PGPUB; USPAT; EPO; JPO; IBM_TDB	OR	ON	2005/11/09 10:59
S20	1916	substrate and (nitrogen adj plasma)	US-PGPUB; USPAT; EPO; JPO; IBM_TDB	OR	ON	2005/11/09 10:58.
S21	387	S20 and (electric adj field)	US-PGPUB; USPAT; EPO; JPO; IBM_TDB	OR	ON	2005/11/09 12:08
; S22	1	S21 and (pulse adj modulation)	US-PGPUB; USPAT; EPO; JPO; IBM_TDB	OR	ON	2005/11/09 10:58
. S23	68	S21 and pulse	US-PGPUB; USPAT; EPO; JPO; IBM_TDB	OR	ON	2005/11/09 10:59
S24	16	S23 and aperture	US-PGPUB; USPAT; EPO; JPO; IBM_TDB	OR	ON	2005/11/09 15:21

S25	1916	substrate and (nitrogen adj plasma)	US-PGPUB; USPAT; EPO; JPO; IBM_TDB	OR	ON	2005/11/09 15:22
S26	387	S25 and (electric adj field)	US-PGPUB; USPAT; EPO; JPO; IBM_TDB	OR	ON	2005/11/09 12:08
S28	15	(nitrogen adj plasma) with (electric adj field)	US-PGPUB; USPAT; EPO; JPO; IBM_TDB	OR	ON	2005/11/09 15:32
S29	32	(nitrogen adj plasma) same (electric adj field)	US-PGPUB; USPAT; EPO; JPO; IBM_TDB	OR	ON	2005/11/09 14:49
S30	1	S29 and (pulse adj modulation)	US-PGPUB; USPAT; EPO; JPO; IBM_TDB	OR	ON	2005/11/09 14:58